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APPLICATION N	0.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/632,582		07/31/2003	Ilan Gavish	42P10059CD	5004	
8791	7590	01/23/2004		EXAN		
		OLOFF TAYLOR & BOULEVARD, SEVE	HASSANZADEH, PARVIZ			
	DS ANGELES, CA 90025			ART UNIT	PAPER NUMBER	
				1763		
				DATE MAILED: 01/02/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

Ą		Application No.	Applicant(s)				
	Office Action Summary	10/632,582	GAVISH ET AL.				
7	Ome Action Summary	Examiner	Art Unit				
	The MAILING DATE of this communication and	Parviz Hassanzadeh	1763				
	The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address				
	A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - Failure to reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any Status						
i	1) Responsive to communication(s) filed on <u>02 September 2003</u> .						
	2a) This action is FINAL . 2b) This action is non-final.						
	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Experts. Our day 1005 0.78						
	The practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213						
	Disposition of Claims						
	4)⊠ Claim(s) <u>1-12</u> is/are pending in the application.						
	4a) Of the above claim(s) is/are withdrawn from consideration.						
	5)LJ Claim(s) is/are allowed.						
	6)⊠ Claim(s) <u>1-12</u> is/are rejected.						
	7) Claim(s) is/are objected to.						
	8) Claim(s) are subject to restriction and/or election requirement.						
	Application Papers						
	9) The specification is objected to by the Examiner.						
	10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a)						
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to Soc 37 CER 4 434(4)						
ļ	The path of declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152						
	Priority under 35 U.S.C. §§ 119 and 120						
	12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
	1. Certified copies of the priority documents have been required.						
	2. Certilled copies of the priority documents have been received in Application 14.						
	application from the International Bureau (PCT Bulg 17.2(a))						
	See the attached detailed Office action for a liet of the contisted continuously and the second seco						
	Additional and the state of a claim for domestic priority under 25 11 C C 2 440(2) (1)						
	37 CFR 1.78.						
	a) The translation of the foreign language provisional application has been received						
	14)⊠ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121 since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78.						
4	Attachment(s)						
1	1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO 048) 4) Interview Summary (PTO-413) Paper No(s)						
3)		rot Application (PTO-152)				
U.S. PT	Patent and Trademark Office OL-326 (Rev. 11-03) Office Action	1 Summary	Part of Paper No. 12/2003				

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DETAILED ACTION

Specification

The disclosure is objected to because of the following informalities: it is suggested to update the information on the related applications recited on page 1, for example, the application with serial No. 10/209,983 is now US Patent No. 6,627,538 B2.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 1-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ohnishi et al (US Patent No. 5,120,925) in view of Drummond et al (US Patent No. 5,132,248).

Ohnishi et al teach a system (Figs. 2, 3) comprising:

a chamber housing a substrate 200;

an ion beam 100 (energy source) coupled to the chamber;

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a system controller 550 to control introduction of metal precursor gas 110 to a focus ion beam 1 and to control the ion beam generating unit, wherein the computer 500 includes a memory having computer-readable program for controlling the operation of the system.

Ohnishi et al fail to teach a coherent electromagnetic radiation source to heat a metal layer formed on the substrate.

Drummond et al teach an apparatus for forming a metal deposition on the surface of a substrate, wherein the metal layer on the substrate is annealed by a radiation light source such as a laser source (Fig. 1; column 3, lines 65-68; column 5, lines 27-37).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to implement the laser source as taught by Drummond et al in the system of Ohnishi et al in order to anneal the metal film formed on the substrate.

Further regarding claims 2, 3, 8-10: The type of the metal, the chamber pressure, and the thickness of the formed layer are considered process limitation rather than structural limitations and the apparatus as discussed above is capable of being used for forming, for example, platinum under the condition recited in the claims.

The particular type of gas used is a process limitation rather than an apparatus limitation, and the recitation of a particular type of gas does not limit an apparatus claim, see *In re Casey*, 152 USPQ 235; *In re Rishoi*, 94 USPQ 71; *In re Young*, 25 USPQ 69; *In re Dulberg*, 129 USPQ 348; *Ex parte Thibault*, 64 USPQ 666; and *Ex parte Masham*, 2 USPQ2d 1647. This rejection is based on the fact the apparatus structure taught by prior art has the inherent capability of being used in the manner intended by the Applicant. When a rejection is based on the inherency, a

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rejection under 35 U.S.C. 102 or U.S.C. 103 is appropriate. (See *In re Fitzgerald* 205 USPQ 594 or MPEP 2112)

It has been held that claims directed to apparatus must be distinguished from the prior art in terms of structure rather than function. *In re Danley*, 120 USPQ 528, 531, (CCPQ 1959); "Apparatus claims cover what a device is, not what a device does" (Emphasis in original) *Hewlett-Packard Co. V. Bausch & Lomb Inc.*, 15USPQ2d 1525, 1528 (Fed. Cir. 1990); and a claim containing a "recitation with respect to the manner in which a claimed apparatus is intended to be employed dos not differentiate the claimed apparatus from a prior art apparatus" if the prior art apparatus teaches all the <u>structural</u> limitations of the claim *Ex parte Masham*, 2 USPQ2d 1647 (Bd. Pat. App. & Inter. 1987). Also see MPEP 2114.

Further regarding claims 4-7: The ion beam taught by Ohnishi et al is a focus ion beam and thus would inherently heat a discrete area on the layer; the radiation source as taught by Drummond et al is preferably a laser source including laser optics for focusing the laser to a spot size on the layer. Further, the selection of an appropriate lens for the laser radiation is considered to have been obvious to one of ordinary skill in the art at the time of the invention in order to focus the radiation to a desired spot size.

Further regarding claims 11, 12: It is held in re Harza, 274 F.2d 669, 124 USPQ 378 (CCPA 1960) that a mere duplication of parts has no patentable significance unless a new and unexpected result is produced therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to include a plurality of metal precursor gases in order to introduce different metal precursor gases into the chamber separately or simultaneously as desired.

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Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1-12 are provisionally rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-6 of copending Application No. 10/209,453. Although the conflicting claims are not identical, they are not patentably distinct from each other because the structural limitations in both cases are obvious and similar variation of each other.

This is a <u>provisional</u> obviousness-type double patenting rejection because the conflicting claims have not in fact been patented.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Tao et al (US Patent No. 5,104,684) teach an ion beam metal deposition system;

Azuma et al (US Patent No. 5,976,328) teach an ion beam processing system wherein the surface of a metal film is heated by a radiation source (column 7, lines 24-68).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Parviz Hassanzadeh whose telephone number is (571)272-1435. The examiner can normally be reached on Tuesday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (703)308-1633. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0661.

Parviz Hassanzadeh Primary Examiner Art Unit 1763

December 30, 2003